

**Wet-Burn-Wet Abatement
Evaluation on 300mm Silicon Nitride
Deposition**

SESHA Conference 2017

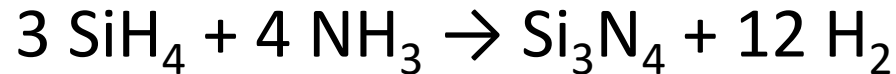
Agenda Outline

- Introduction and Objectives
- Test Setup and Timeline
- Chamber Cleaning Test Results
- Deposition Process Test Results
- Discussion
- Questions

Introduction and Objectives

Silicon Nitride Deposition

- Silicon Nitride is typically used in semiconductors as a dielectric, oxidation mask or a passivation layer



- Process flows also include a carrier gas and possibly N₂O
- As required, removal of deposits from tool reaction chamber walls requires a chamber cleaning step often through flows of NF₃ and carrier gases

Burn-Wet Operation Summary

SiN – Dep Process Abatement

Gases Put Into
Burner

Process Step

SiH₄

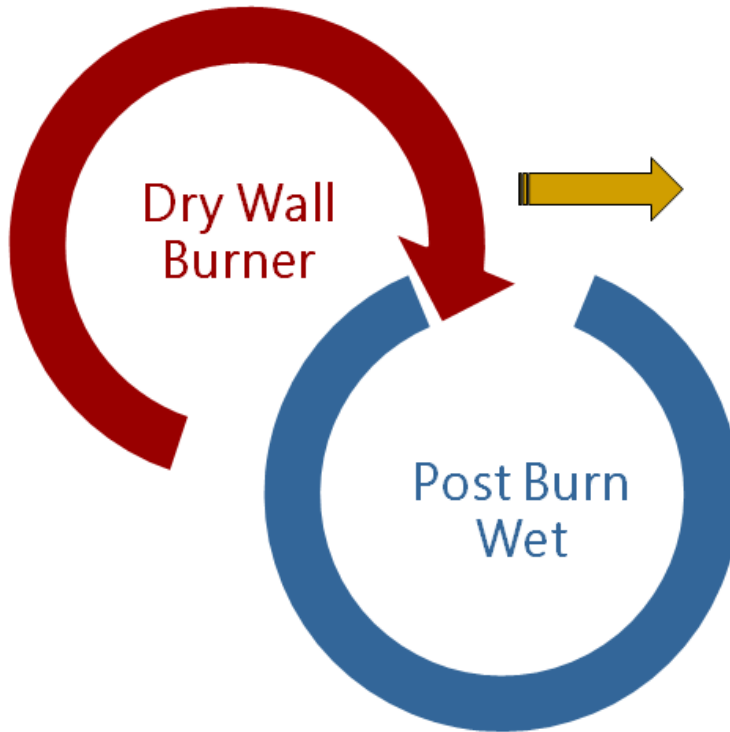
NH₃

Clean Step

C₂F₆/NF₃

HF/F₂

SiF₄



Burner
Output

Si-Deposits

Si-particles

NH₄F Sub- μ
particles

High NO_x

HF

Wet-Burn-Wet Operation Summary

SiN – Dep Process Abatement

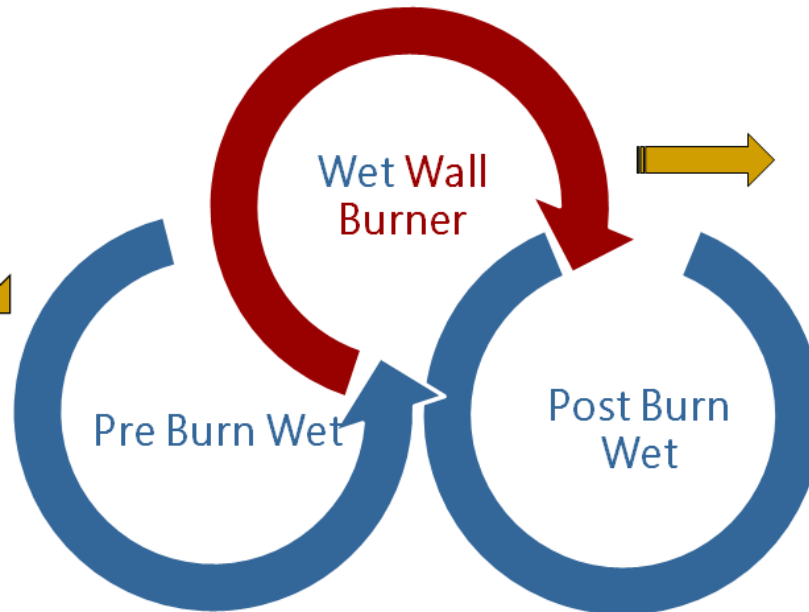
Gases Put Into
Burner

Process Step

SiH₄

Clean Step

C₂F₆/NF₃



Burner
Output

SiO₂- Particles

NH₄F Particles

(reduced)

No Excess NO_x

From NH₃ Burn

HF

Removed by Pre Wet

NH₃

HF/F₂

Chamber clean byproducts

Project Scope

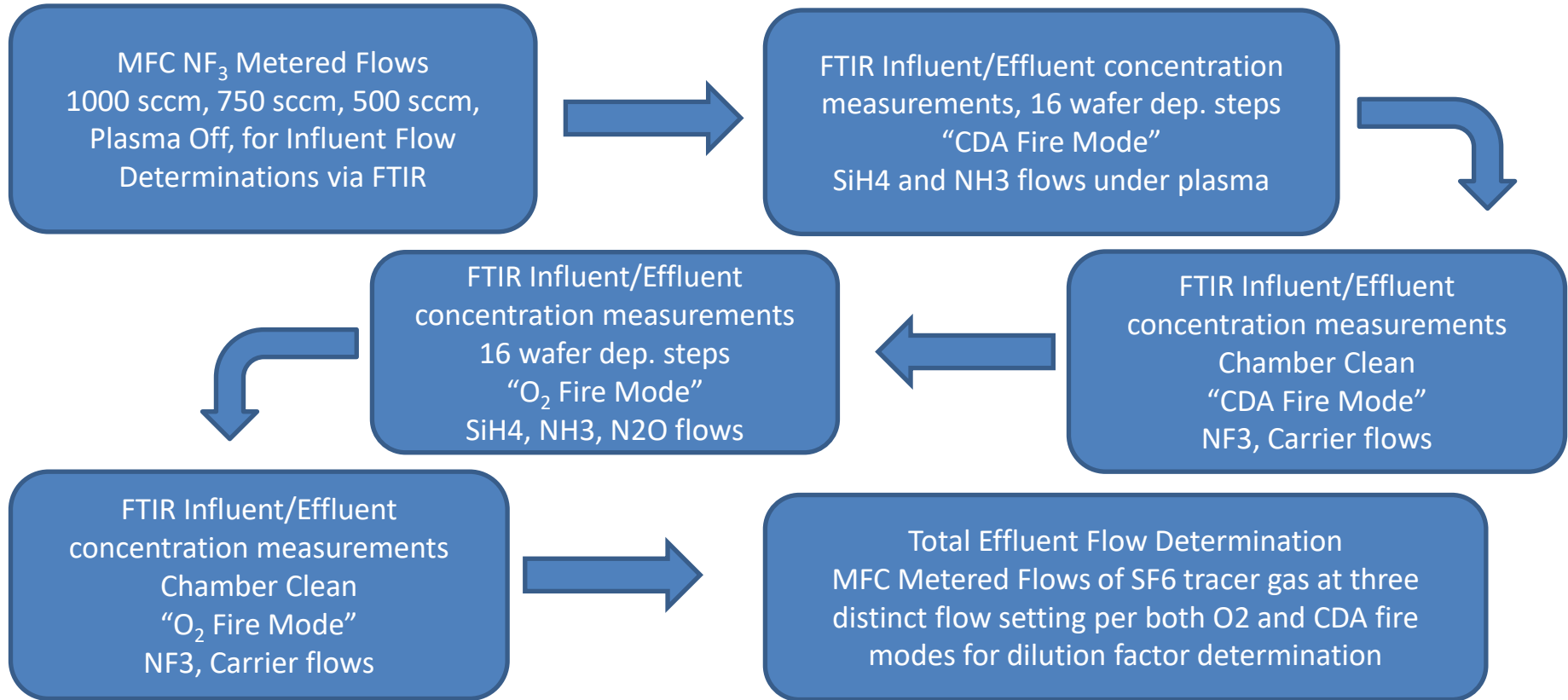
- Evaluate an Airgard Encompass wet-burn-wet abatement unit for performance against currently installed TPU-4 burn-wet abatement unit
 - Remove ammonia prior to house exhaust system
 - Concerns regarding excess ammonium fluoride particulates
 - Concerns regarding excess NO_x generated due to ammonia
- Further concerns regarding Greenhouse Gas Destruction
 - NF₃ DRE
 - N₂O DRE and effects on NO_x
 - Performance with CDA and O₂
- Reliability and maintenance of unit

Test Setup and Timeline

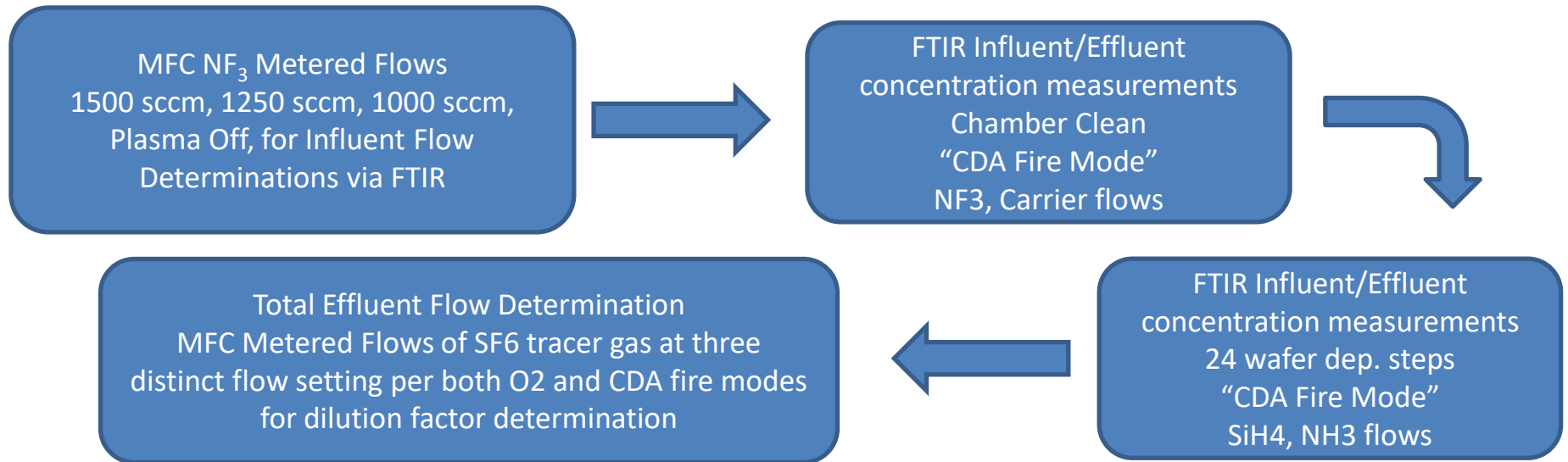
Testing Method

- Extractive Fourier Transform Infrared (FTIR) Spectroscopy
- Procedures were consistent with EPA Protocol for Measuring Destruction or Removal Efficiency of Fluorinated Greenhouse Gas Abatement Equipment in Electronics Manufacturing (March 2010)
- Data was gathered using Method 2, “Total Volume Measurements”, which measures DREs under actual process conditions where byproducts are formed and analytical determined influent/effluent exhaust flows were performed via process NF_3 or SF_6 tracer gas injection

Timeline for Encompass Testing (Day 1)



Timeline for TPU Testing (Day 2)



Average Influent/Effluent Flows and DFs

Encompass Avg. Influent Flow	43.0 slm
TPU Avg. Influent Flow	44.5 slm
Encompass Avg. Effluent Flow, O ₂ Fire	145 slm
Encompass Avg. Effluent Flow, CDA Fire	410 slm
TPU Avg. Effluent Flow, CDA Fire	419 slm
Encompass O₂ Fire DF	3.4
Encompass CDA Fire DF	9.5
TPU CDA Fire DF	9.4

Chamber Clean Step Results

Chamber Clean Testing Objectives

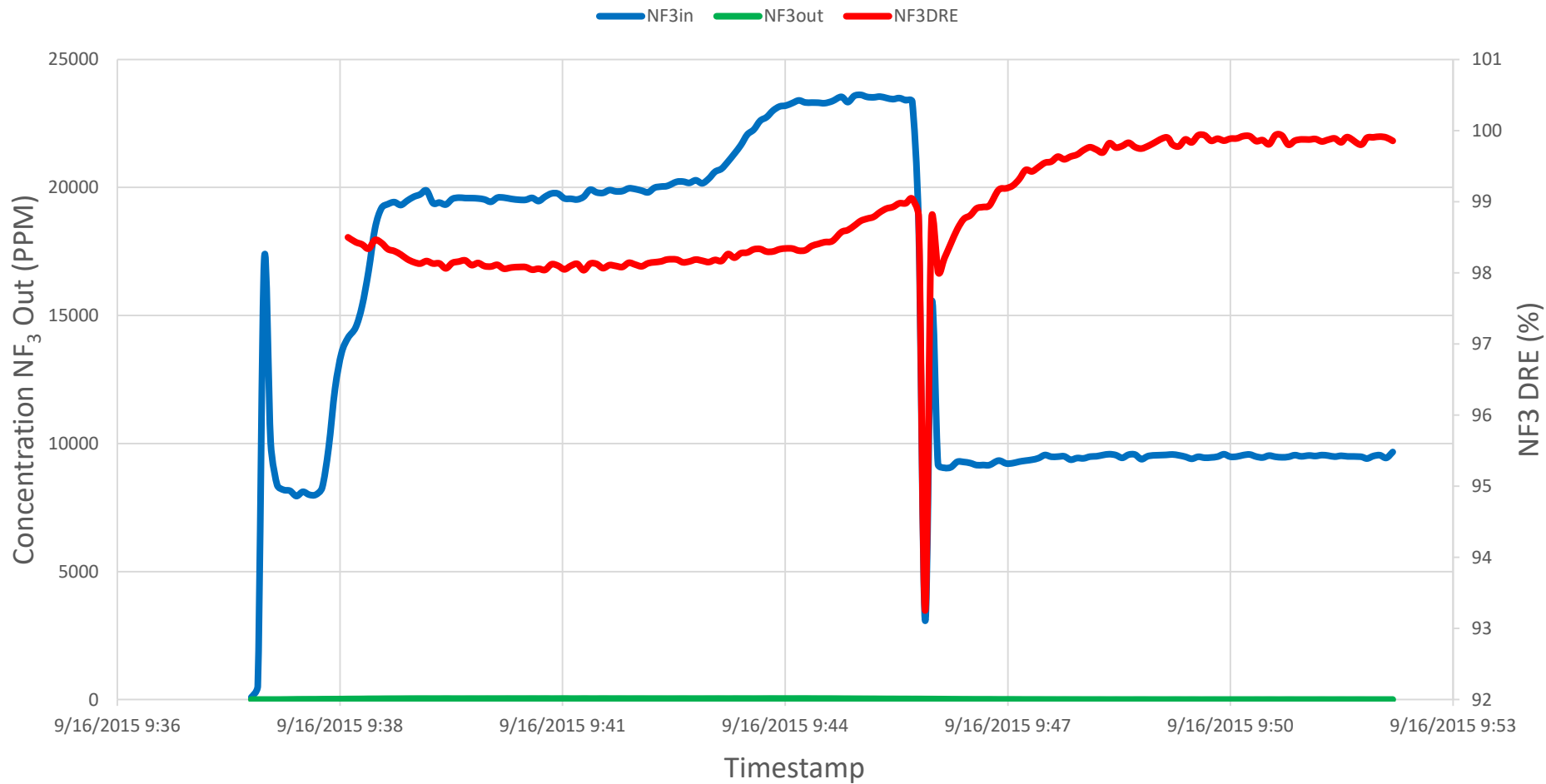
- What is the effective DRE for NF₃?
- Is there appreciable destruction of NF₃ in “CDA fire” mode?

Certain fabs do not have available O₂ supplies plumbed throughout the support level

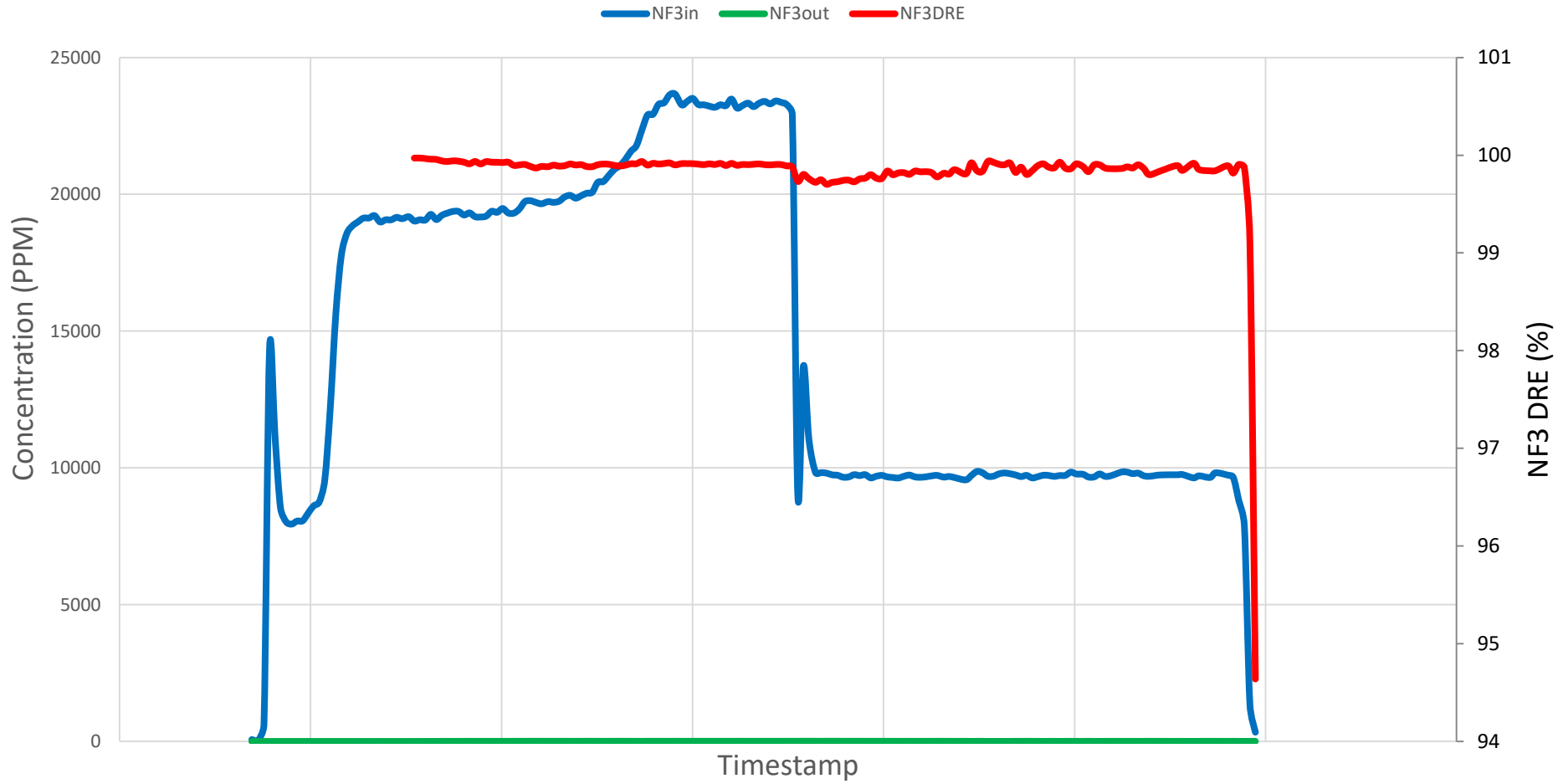
To claim abatement, MRR requires fabs to test their abatement units

- Are there differences in levels of NO_x generated between the abatement units?

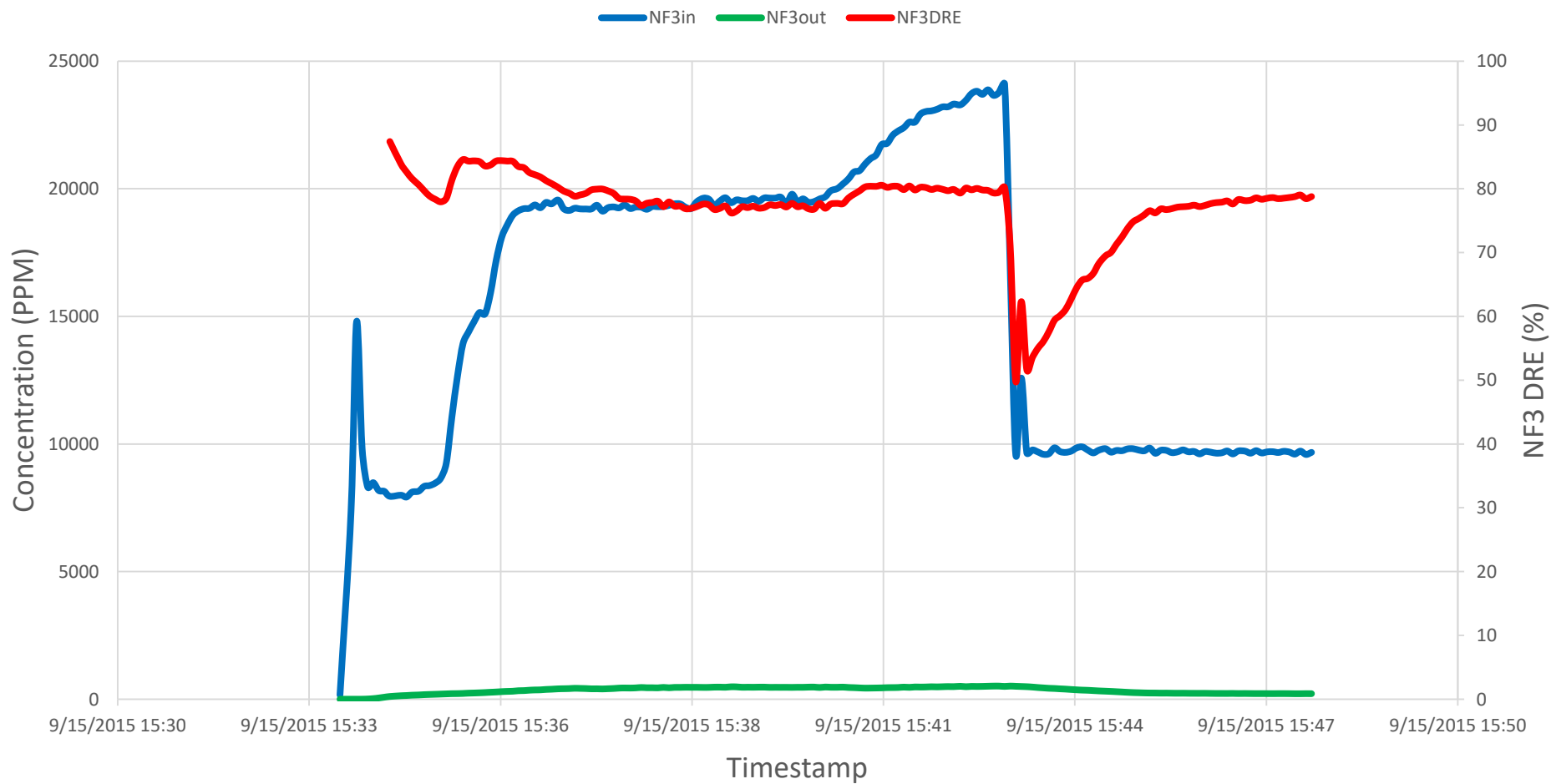
TPU NF₃ DRE in "CDA Fire"



Encompass NF₃ DRE in "O₂ Fire"



Encompass NF₃ DRE in "CDA Fire"



NF3 DRE Results

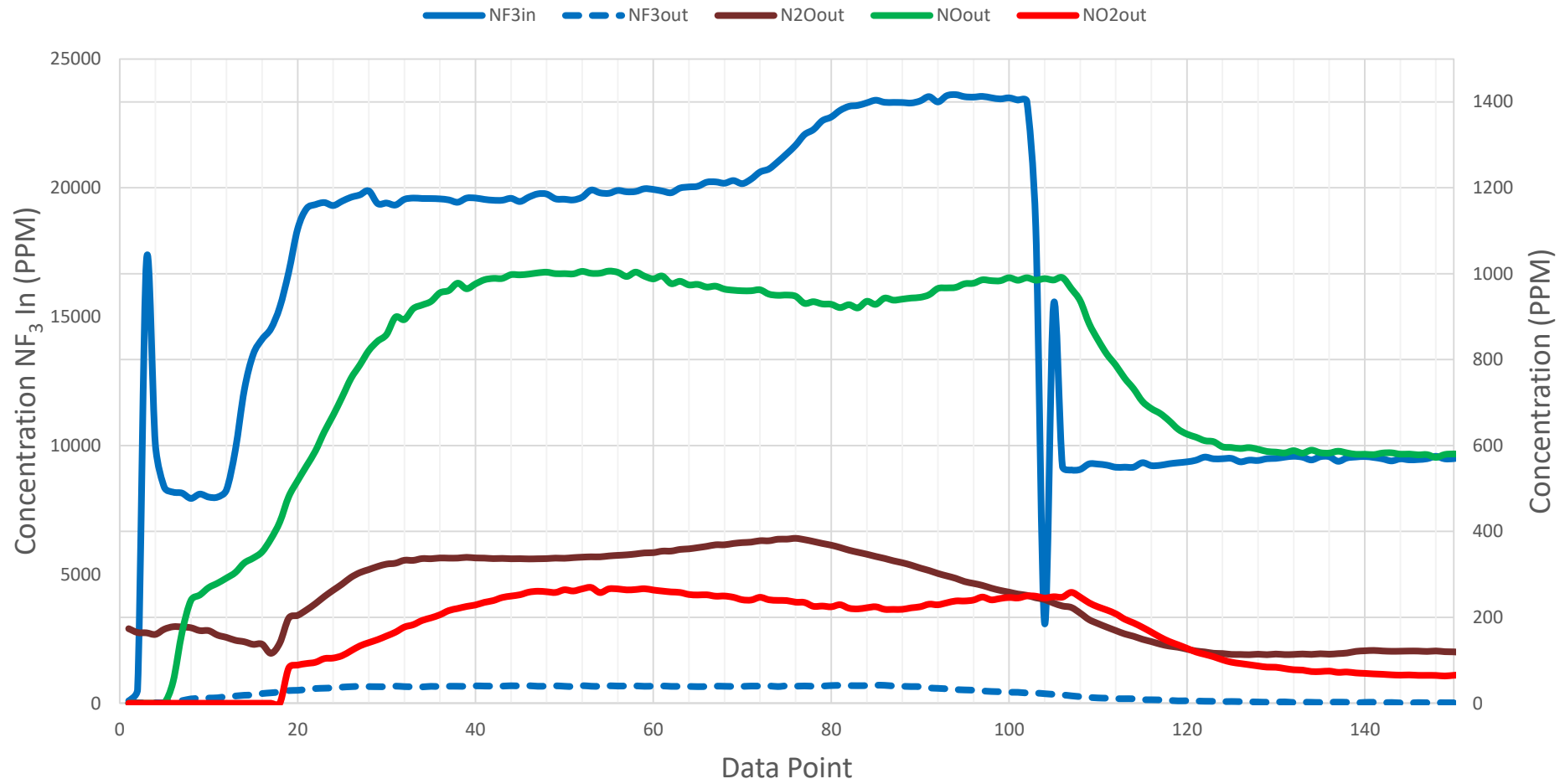
- Both Encompass operating in “O2 fire” mode and TPU in “CDA fire” mode achieved average DREs of about 99%.

Extensive maintenance of the TPU was performed one day prior to testing including the combustor liner

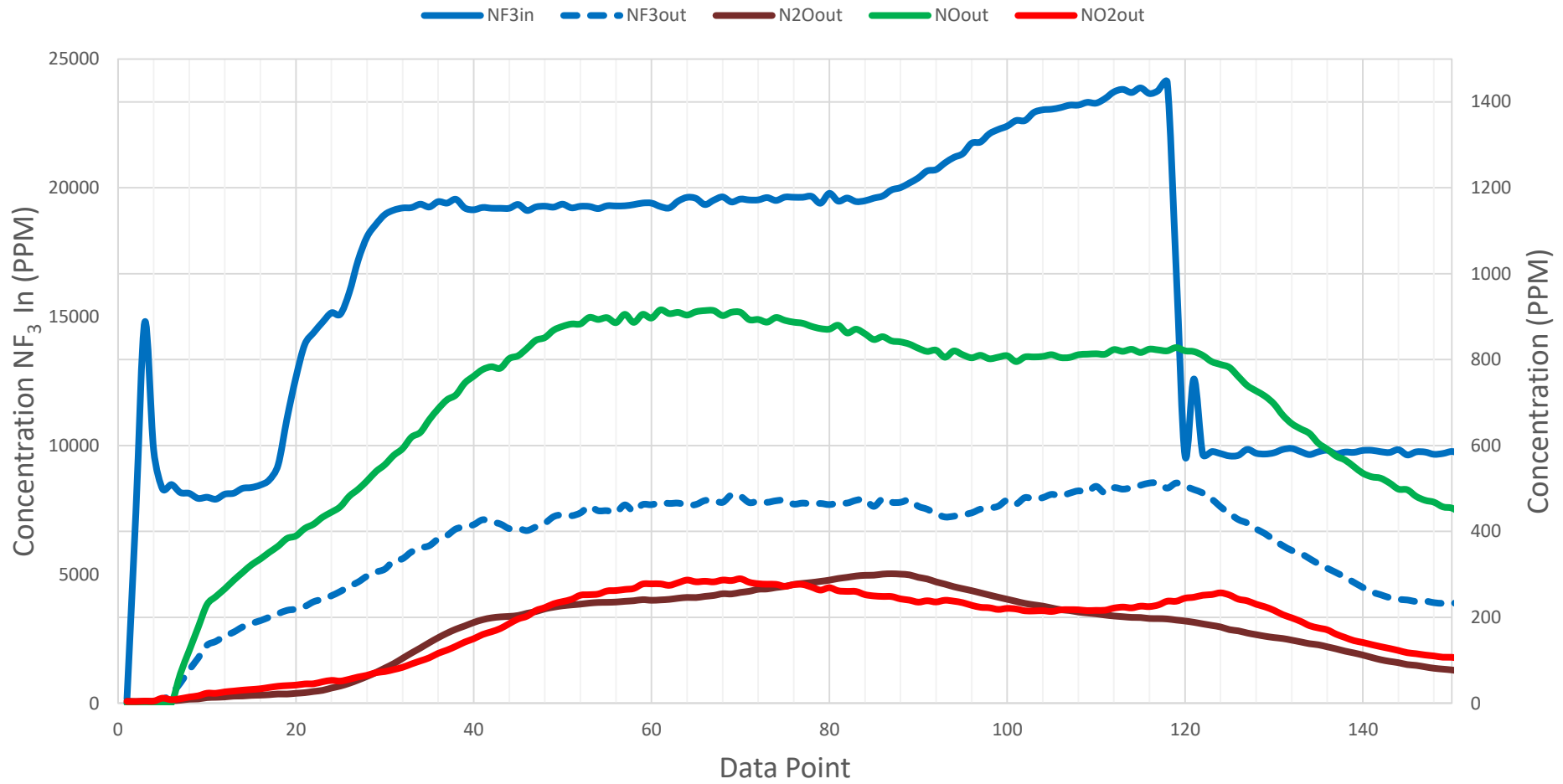
Previous testing by TI on other TPUs at another TI facility indicates that DRE is greatly affected by combustor liner plugging

- The average DRE for the Encompass in “CDA fire” mode was ~80%
- EPA Subpart I default DRE for NF3 is 88% from Table I-16

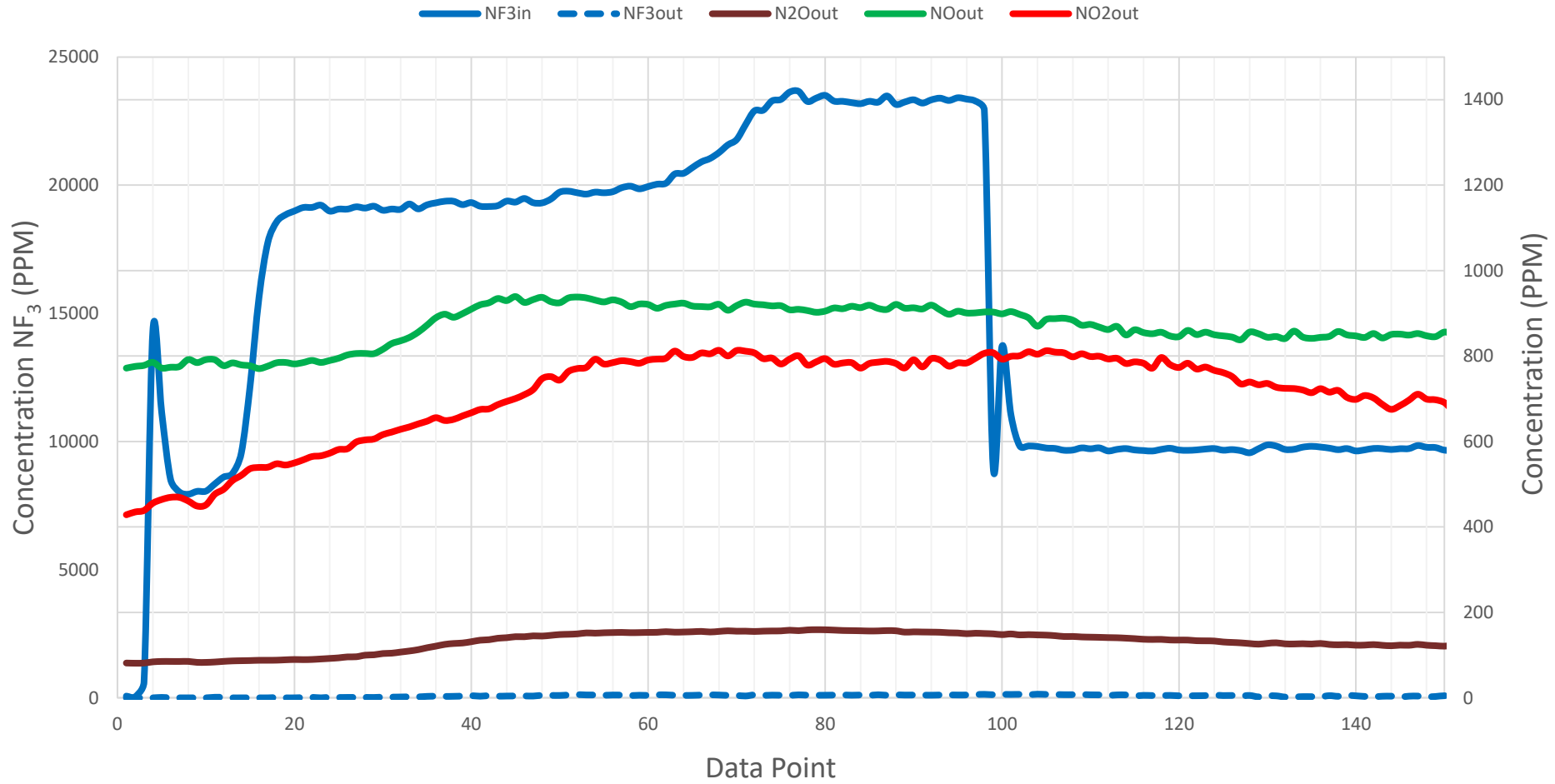
TPU Chamber Clean with "O₂ Fire"



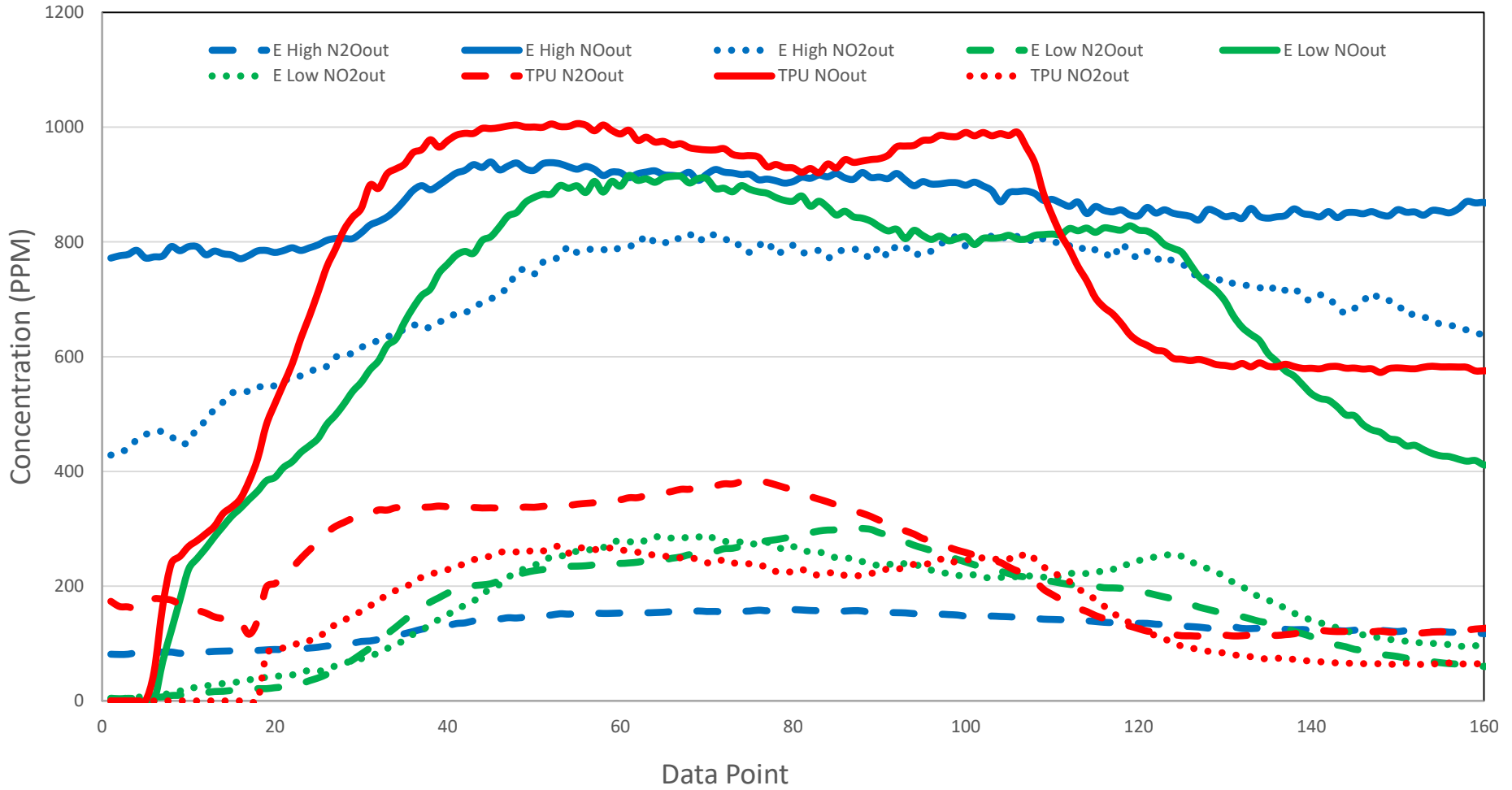
Encompass NF3 Chamber Clean with "CDA Fire"



Encompass NF₃ Chamber Clean with "O₂ Fire"



NOx Outlet Comparison Combined



Chamber Clean NO_x Results

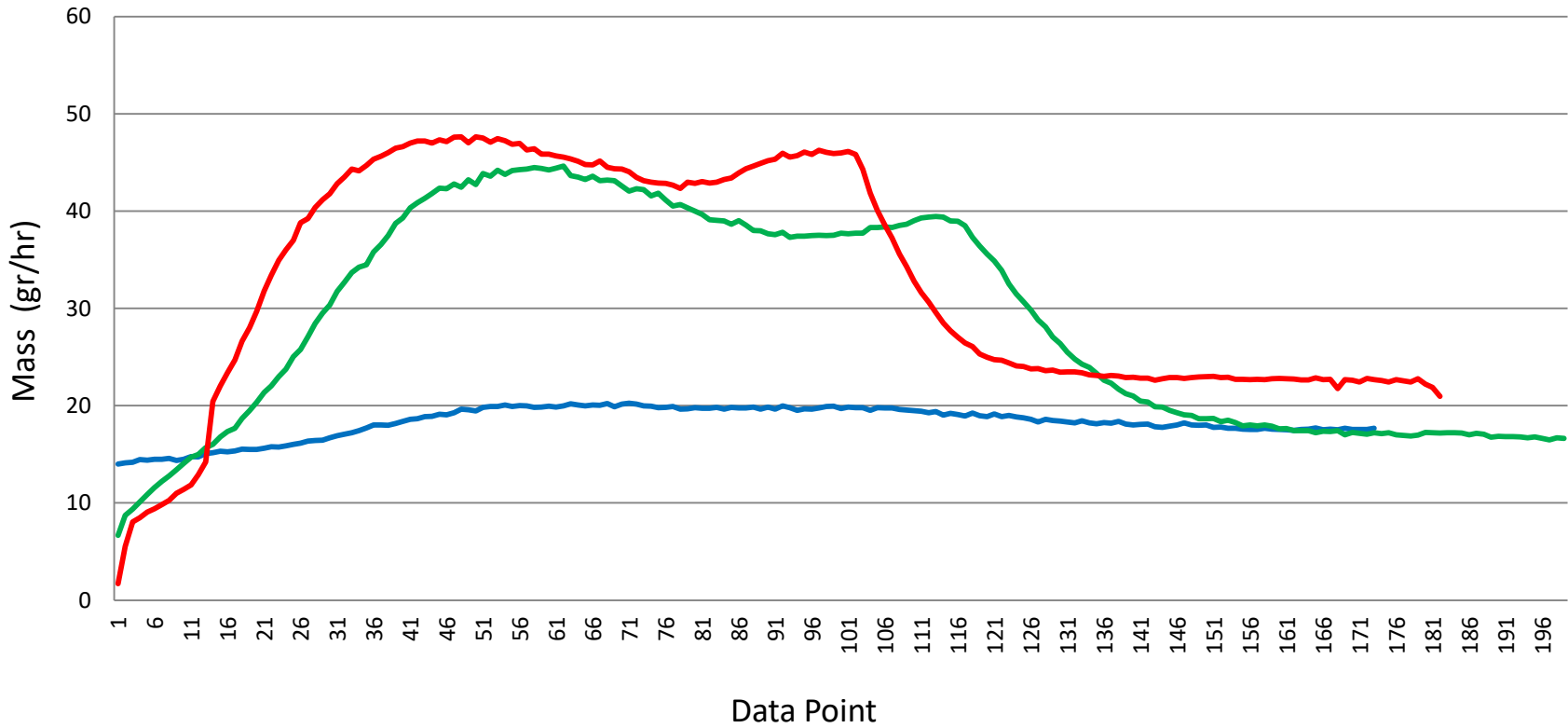
- The Encompass abatement unit running in “CDA fire” mode was very comparable to the TPU also in “CDA fire” mode

	Avg. NO (ppmv)	Avg. NO ₂ (ppmv)	Avg. N ₂ O (ppmv)
Encompass @ CDA Fire	645	169	152
TPU (CDA Fire)	787	163	236

- The two also have similar dilution factors
- The NO_x concentration was markedly higher for the Encompass unit running in “O₂ fire” mode
 - This is expected as higher temperatures will favor NO₂ production
 - Interestingly, due to the lower total flow rate, the mass flow of NO_x is actually less than the CDA fire modes

Mass Flow Rate of NOx

Encompass O2 Fire Encompass CDA Fire TPU CDA Fire

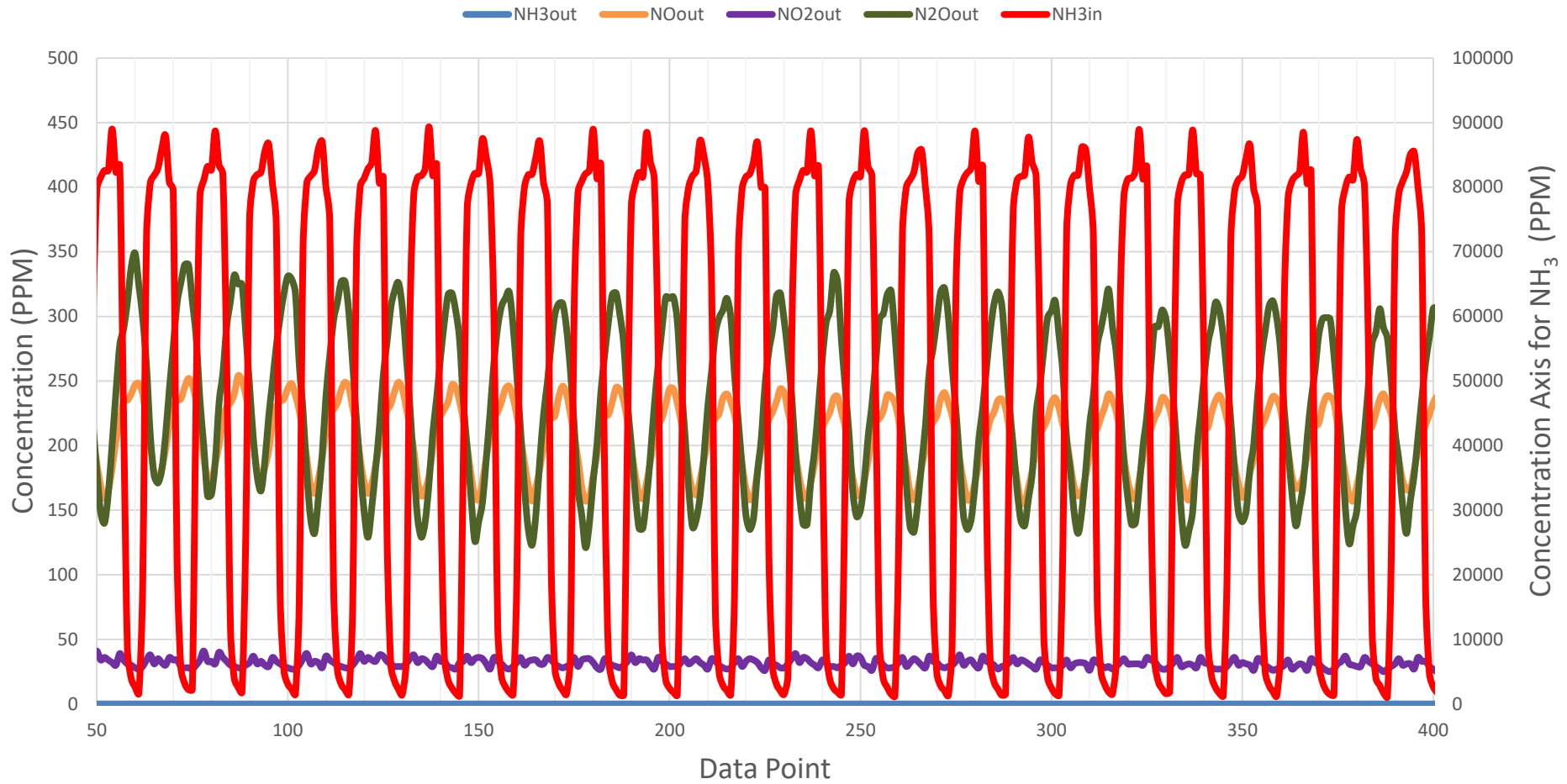


Process Step Results

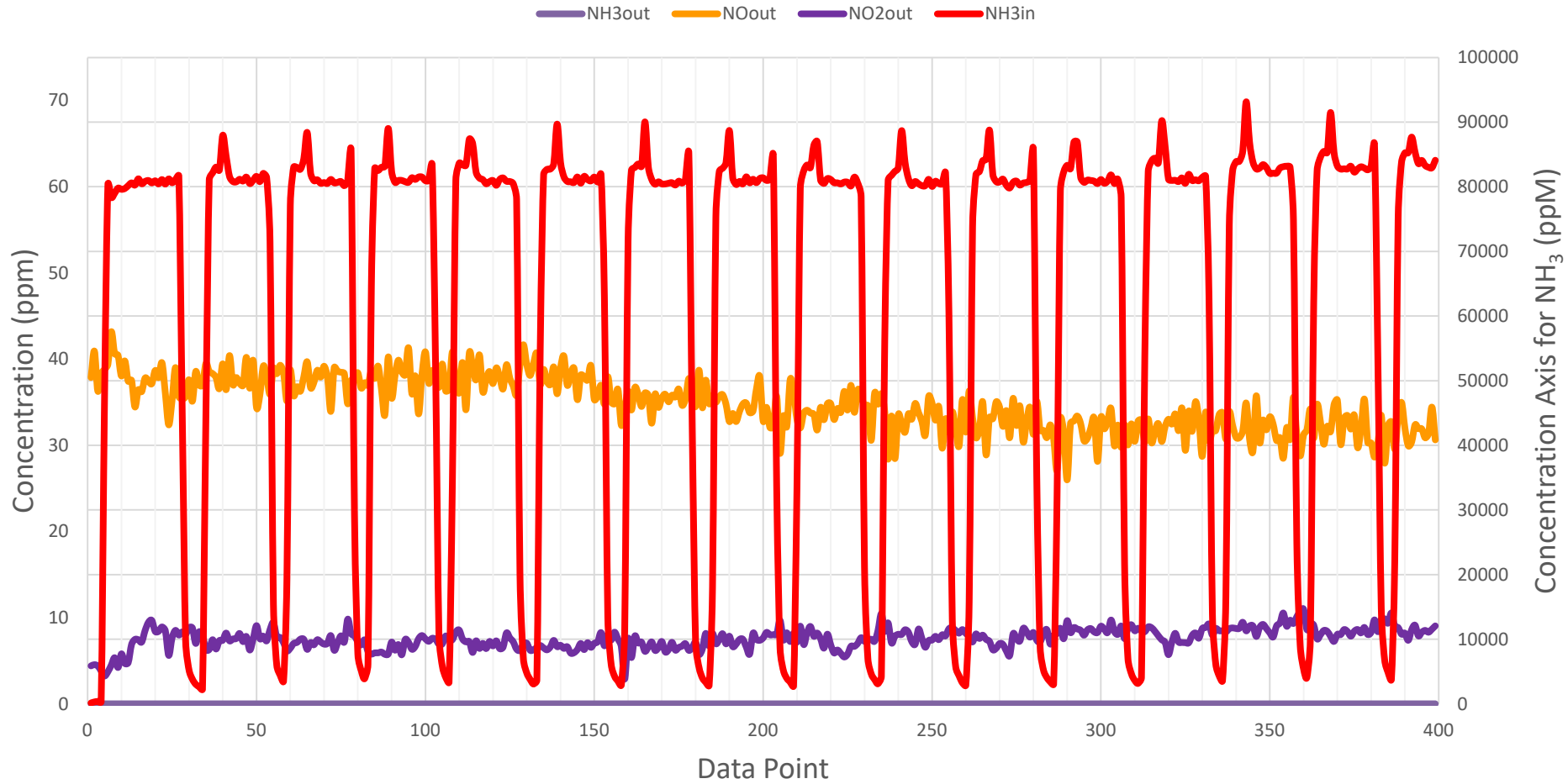
Process Step Testing Objectives

- What is the NH₃ Removal Efficiency?
- Does the Encompass wet-burn-wet first stage remove the NH₃ effectively and what are the differences in NO_x production?

TPU Silicon Nitride Deposition Process with "CDA Fire"

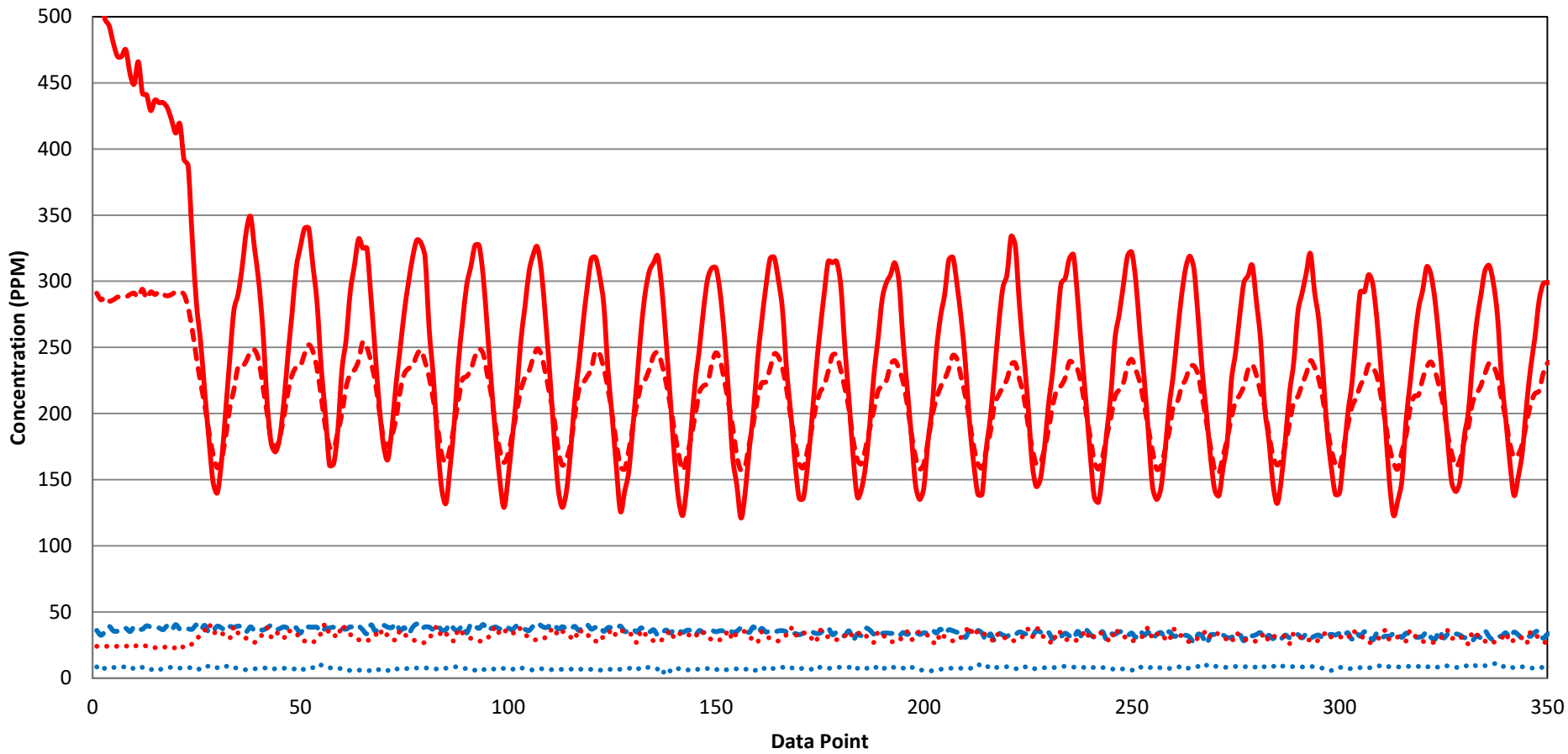


Encompass Silicon Nitride Deposition Process with "CDA Fire"



Encompass CDA Versus TPU CDA NO_x Out (Process Emissions)

Enc CDA NOout Enc CDA NO2out TPU NOout TPU NO2out TPU N2Oout

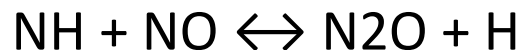


Process Step NO_x Results

- Again, the Encompass abatement unit running in “CDA fire” mode was very comparable to the TPU also in “CDA fire” mode. The inlet concentrations of NH₃ were pretty much identical.

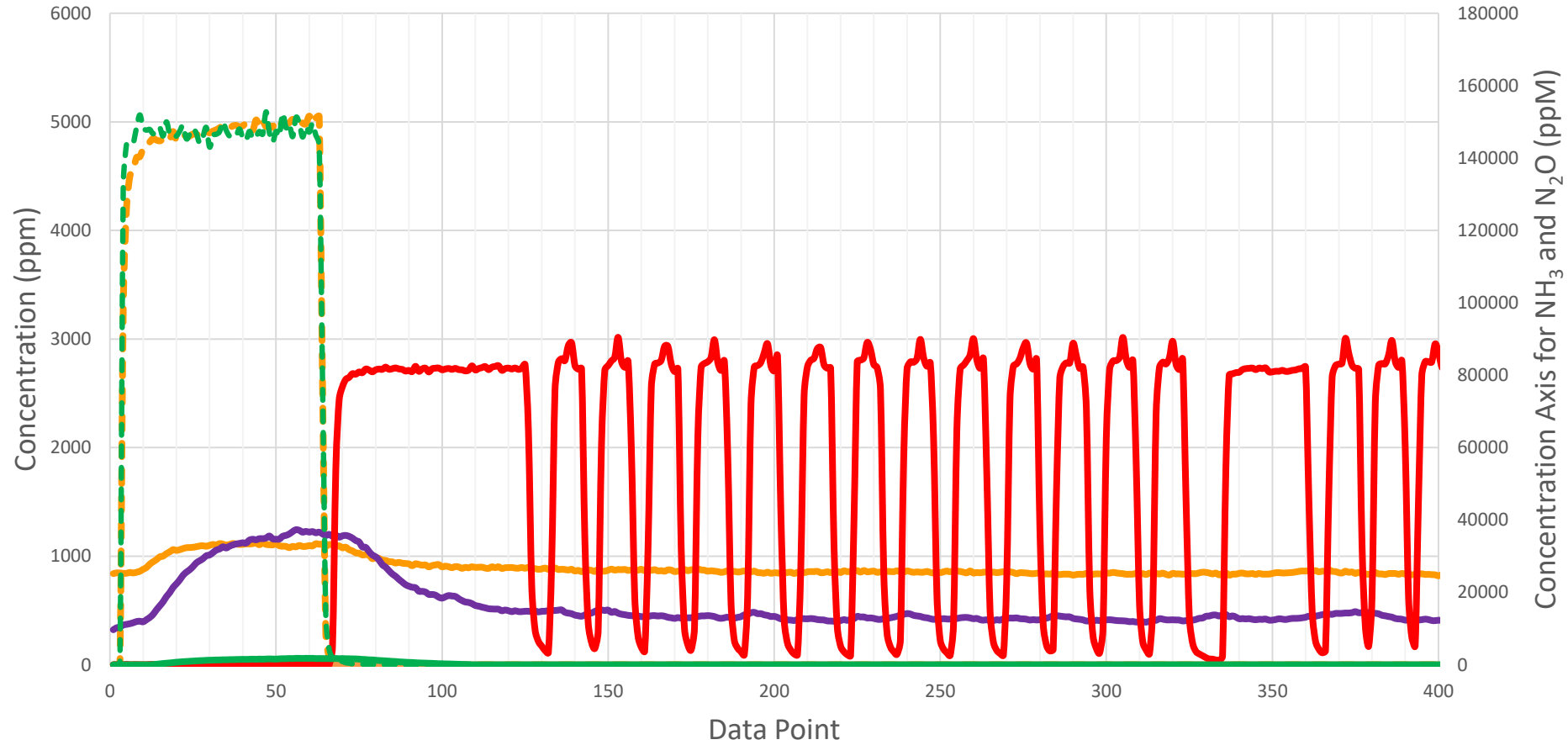
	Avg. NO (ppmv)	Avg. NO ₂ (ppmv)	Avg. N ₂ O (ppmv)
Encompass @ CDA Fire	34	8	< 10
TPU (CDA Fire)	212	31	251

- Appears that the first stage wet scrubber which allows removal of excess NH₃ prior to the burn chamber, makes a significant difference in NO_x and N₂O production. It is believed that excess NH can react with NO to produce N₂O.



Encompass Silicon Nitride Deposition Process with Undercoat and "O₂ Fire"

NOin NH3out NOout NO2out NH3in N2Oin N2Oout



Process Step NO_x Results (cont.)

- The Encompass running in “O₂ fire” mode data seems to back up the efficacy of the first stage wet-scrubber as the N₂O levels drop below detect after the pre-coat step.
- The N₂O destruction efficiency of the Encompass in “O₂ fire” mode also averaged ~99% although we do see increases in NO_x production in the effluent as expected.
- It is also evident that the N₂O/NO_x levels did not fluctuate with NH₃ input as seen in the TPU.

Miscellaneous Discussion

Utility and Maintenance

- Utilities forecasted for the Encompass were comparable to that of the existing Edwards TPU
- Final cost analysis showed an increase of about 20% from forecasted costs, mainly due to water usage. However the costs of operation of the Encompass unit was still comparable to the TPU.
- The Encompass unit, once the testing was done, ran for ~13 months without maintenance needed. Repairs were needed after the unit developed a water leak. This ability to run without maintenance reduces the cost of operation of the Encompass significantly versus the TPU. Estimates show overall a difference of ~60% savings.
- Although particulates were not quantified, it was noticed that the Encompass effluent seemed to have a higher concentration of aerosol particulates than the TPU. It is theorized that the particulates may have been trapped by the ceramic liner used by the TPU. This is partially evident in the Encompass' ability to run continuously without need for maintenance.

NO_x and DRE Discussion

- It is important to take into account that NO_x production is a complex issue and that the burners in both the Encompass and TPU unit were not tuned to minimize NO_x prior to testing.
- In developing the Mandatory Reporting Rule Subpart I, EPA concluded that maintenance performed on an abatement unit could affect the DRE for greenhouse gases. Lowering the frequency of maintenance can give greater confidence that a unit is achieving the require DREs. Also, internal testing at TI has shown that TPU DRE degrades over time as chamber liner plugs up during normal processing.
- Also, as buildup in the combustion chamber is minimal (due to the Encompass Wetted Wall technology), maintenance is not expected to have any effect on DRE.

Future Evaluation Considerations

- Next step could potentially be to measure DREs again to track possible degradation over time of NF₃
- Results from the wet-burn-wet technology seems promising in removing unwanted chemistries from reaching the combustion chamber. TI plans to evaluate a unit for tungsten oxide deposition